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# On-surface products from de-fluorination of C<sub>60</sub>F<sub>48</sub> on Ag(111): C<sub>60</sub>, C<sub>60</sub>F<sub>x</sub> and silver fluoride formation†

E. Barrena, \*<sup>a</sup> R. Palacios-Rivera, <sup>a</sup> A. Babuji,<sup>a</sup> L. Schio, <sup>b</sup> M. Tormen, <sup>b</sup> L. Floreano \*<sup>b</sup> and C. Ocal <sup>a</sup>

By employing diverse surface sensitive synchrotron radiation spectroscopies we demonstrate that the fluorine content of initial C<sub>60</sub>F<sub>48</sub> deposited at room temperature on Ag(111) varies with molecular coverage. At the very early stages of deposition, C<sub>60</sub>F<sub>48</sub> fully de-fluorinates and transforms into C<sub>60</sub>. Strong indications of silver fluoride formation are provided. The chemical footprint of fluorinated fullerenes emerges at relatively low molecular coverage indicating that the degree of fullerene de-fluorination decreases (from total to partial de-fluorination) as molecules are deposited. Full de-fluorination stops well before the substrate surface is completely covered by fullerenes. At the molecular level, the fluorine loss observed by spectroscopic techniques is supported by scanning tunneling microscopy imaging. Both molecules and metal surface are importantly involved in the process.

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## Introduction

Molecules on surfaces undergo diverse physical and chemical processes, which may involve reactive processes altering their electronic properties and structural characteristics. Identifying the originated products and clarifying their nature are issues of relevance for understanding the mechanisms that would permit tailoring interfaces or choosing the synthesis routes in the design of on-surface novel nanostructures.<sup>1–3</sup> A successful case is the on-surface synthesis of low dimensional carbon nanostructures, where most coupling reactions rely on de-halogenation of the precursor molecules.<sup>4,5</sup> Detecting the small amounts of halogens involved is challenging and few studies have considered the halogen by-products themselves.<sup>6</sup> In some cases, the halogen atoms participate in the intermediate reaction stages<sup>7</sup> or desorb,<sup>8,9</sup> but in other cases they remain at the metal surface, which may influence and eventually stop the reaction process. A much less studied case of on-surface de-halogenation is the reactive adsorption of fluorinated fullerenes (C<sub>60</sub>F<sub>x</sub>) on some metals.<sup>10–15</sup> Because the increase in fluorine content of C<sub>60</sub>F<sub>x</sub> enhances the acceptor character of the molecule, C<sub>60</sub>F<sub>48</sub> is an excellent molecular p-dopant in organic electronics devices,<sup>16–18</sup>

such as organic field effect transistors (OFETs),<sup>19,20</sup> where the molecular species are in contact with metallic electrodes. Any deviation of the stoichiometry of the molecule at its interface with the metal will cause an imbalance of the energy level alignment at the contact with undesired consequences in the device performance. Similar inconveniences arise from chemical changes in the metal itself.

In a previous work we reported that while C<sub>60</sub>F<sub>48</sub> preserves its chemical structure on Au(111), on more reactive surfaces such as Cu(111) and Ni(111), molecules interacting with the bare metal surface were found to transform into C<sub>60</sub> at room temperature.<sup>14</sup> Unexpectedly, despite the evidence of fullerene de-fluorination on the surface, no metal halide formation was detected in the metal core levels for either of the two cases. This fact indicated that detached fluorine atoms had likely left the surface and entered the gas phase. The efficiency of the fluorine loss process was related to the catalytic power of the particular metal surface. Therefore, in the search for new evidence, in the present work we have extended the investigation to Ag(111), which is expected to have intermediate attributes between Cu(111) and Au(111) in terms of surface reactivity.

Halogen atoms may form chemical bonds with metals with a degree of ionicity that depends on the particular halogen–metal pair. In general, this degree decreases down the row of halogens in the periodic table elements (PTE), from fluorine to iodine. In the particular case of fluorine, the most electro-negative atom in the PTE, the interaction is always rather ionic, though slightly decreasing from Ni and Cu to Pt and Au (left to right and top to bottom in the PTE).<sup>21,22</sup> Rather special is the

<sup>a</sup> Institut de Ciència de Materials de Barcelona (ICMAB-CSIC), Campus UAB, Bellaterra, E-08193, Barcelona, Spain. E-mail: ebarrena@icmab.es

<sup>b</sup> CNR-IOM, Laboratorio Nazionale TASC, Basovizza SS-14, Trieste 34149, Italy. E-mail: floreano@iom.cnr.it

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unconventional case of Ag.<sup>23,24</sup> Indeed, the oxides of silver (along with cadmium) are of interest as they show in X-ray Photoelectron Spectroscopy (XPS) an anomalous negative binding energy (BE) shift compared to the metallic silver (Ag<sup>0</sup>), *i.e.*, BE decreases with increasing oxidation state. The Ag 3d emission shifts by about  $-0.3$  eV and  $-0.8$  eV for AgO and Ag<sub>2</sub>O, respectively, with respect to the Ag<sup>0</sup>.<sup>25</sup> Similarly, the reported BE shifts for AgF and AgF<sub>2</sub> are  $-0.2$  eV and  $-0.7$  eV, respectively.<sup>26,27</sup> While positive shifts in other systems are commonly explained in terms of the electronegativity difference between the metal atom and the cation, the reversed shifts in silver compounds have been subject of controversy. Despite the complexity that all the above confers to the C<sub>60</sub>F<sub>48</sub> on Ag(111) system, we present a C<sub>60</sub>F<sub>48</sub> coverage-dependent study by Synchrotron X-ray photoelectron spectroscopy (XPS) and near-edge X-ray absorption fine structure (NEXAFS), which reveals a detailed scenario of the de-fluorination process and the products of such an on-surface reaction. Overall this work demonstrates significant differences with respect to the other studied close-packed metals where surface-induced de-fluorination of C<sub>60</sub>F<sub>48</sub> occurs (Cu(111) and Ni(111)).

## Methods

### Experimental details

Fluorinated fullerene C<sub>60</sub>F<sub>48</sub> molecules were synthesized as described<sup>28</sup> at the Josef Stefan Institute (Slovenia). The product was characterized by chemical analysis, electron-ionization mass spectrometry and infrared spectroscopy. The purity was estimated to be 95%. Homemade boron nitride crucibles were used to effusively deposit the molecules at typical temperature of 200 °C with an effective deposition rate at the sample in the range of 0.5 Å min<sup>-1</sup>. The amount of evaporated molecules was monitored *in situ* using homemade quartz monitor (QM) balances. For C<sub>60</sub>F<sub>48</sub>, ( $\rho = 2$  g cm<sup>-3</sup>) we assume that 1 nm of nominal thickness approximately corresponds to a single layer of closed-packed molecules (ML). Note that instead, the coverage of fluorine atoms on the substrate is rather dealt in terms of the fcc surface atom density (see ESI†). The Ag(111) single crystal was prepared by repeated cycles of Ar<sup>+</sup> sputtering (1.5 kV) plus annealing at 510 °C. The surface quality, in terms of cleanliness and ordering, was checked by X-ray photoemission (XPS) and electron diffraction (either RHEED or LEED), respectively.

XPS and NEXAFS experiments were performed at the ALOISA beamline of the Elettra synchrotron facility in Trieste (Italy).<sup>29</sup> The core level spectra were recorded using photon energies of 515 eV (C 1s and Ag 3d) and 820 eV (F 1s) with an overall energy resolution of 160 and 300 meV, respectively. The binding energy (BE) scale was calibrated to the Ag 3d<sub>5/2</sub> of the metallic substrate at 368.3 eV. A photon energy of 140 eV (with an energy resolution of  $\Delta \sim 110$  meV) was employed to access the density of states (DOS) at the Fermi-edge valence band (VB). The NEXAFS spectra at the carbon K-shell ionization threshold ( $\Delta \sim 80$  meV) were measured in partial electron yield mode by means of a channeltron equipped with a grid polarized at a

bias of  $\sim 230$  V, in order to reject low energy secondary electrons and let in the C Auger electrons. We collected NEXAFS spectra in s-polarization and (close to) p-polarization by keeping the surface at constant grazing angle of  $\sim 6^\circ$  and rotating the sample around the photon beam axis. The NEXAFS spectra were first calibrated by simultaneous acquisition of the drain current on the last (Au-coated) refocusing mirror, then normalized to reference NEXAFS spectra measured on the clean substrate, as outlined in detail in ref. 30.

Scanning tunnelling microscopy (STM) was performed at room temperature (RT) in a separated UHV chamber equipped with a variable-temperature STM (SPECS Aarhus 150), Low Energy Electron Diffraction (LEED) optics (SPECS erLEED) and a QM microbalance. The same Ag(111) substrate and crucible evaporators were used in both experimental apparatus.

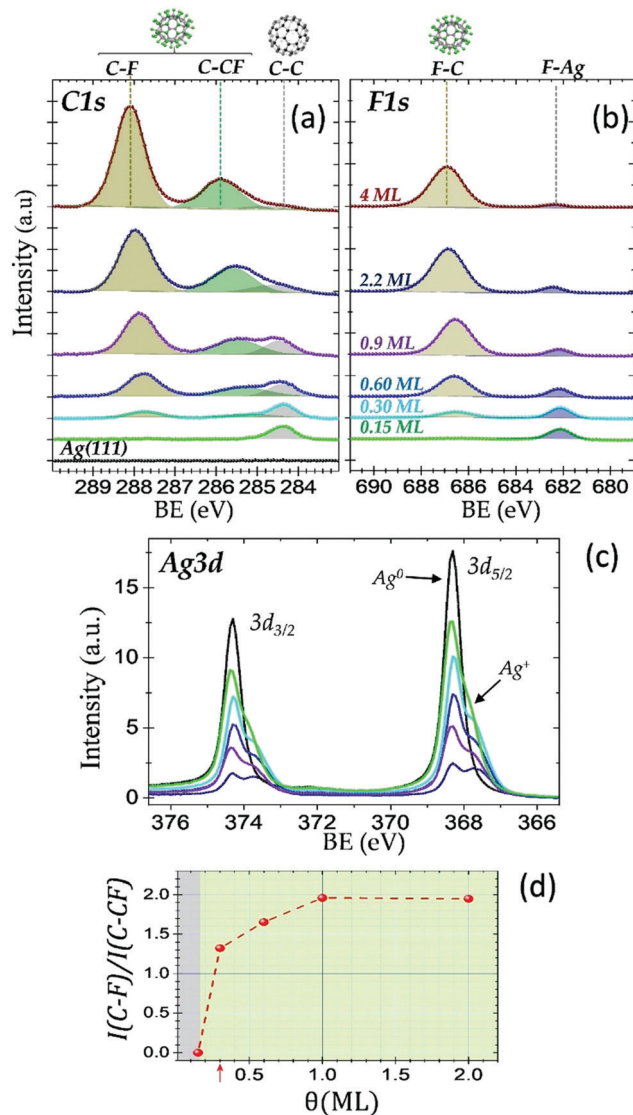
Concerning data analysis, XPS peaks BE positions were calculated from the corresponding data fits using Gaussian or Voigt functions (Shirley type background subtracted). STM images were analyzed using the Gwyddion freeware.<sup>31</sup>

## Results and discussion

For a proper interpretation of the obtained results, it is worth introducing first the core level characteristic fingerprints that fluorinated fullerenes (C<sub>m</sub>F<sub>n</sub>) exhibit in XPS. Two types of C atoms exist in these molecules: (i) carbons bonded to another carbon that in turn bonds to fluorine (C-CF) and (ii) fluorinated carbons that directly bond to fluorine (C-F). Therefore, the fluorine content defined as the number of fluorine atoms per molecule, in principle, can be obtained for a specific fullerene species from the intensity (peak area) ratio between these two peaks in the C 1s core level region. The binding energy (BE) of the corresponding peaks are BE(C-CF)  $\approx 285$ – $286$  eV and BE(C-F)  $\approx 288$ – $289$  eV, clearly larger than the known values BE(C=C)  $\approx 284$ – $285$  eV for the carbon to carbon double bond (C=C) measured for C<sub>60</sub>. Moreover, C-CF has a BE that increases with fluorine content.<sup>32</sup> Similarly, fluorine atoms bonded to carbon atoms (F-C) would present F 1s core level BE(F-C)  $\approx 686$ – $688$  eV, well apart from any metal fluoride signal, BE(F-metal)  $\approx 682$  eV. These emissions, signature of fluorinated and non-fluorinated fullerenes, are indicated in the upper part of the respective panels in Fig. 1.

The evolution of the C<sub>60</sub>F<sub>48</sub> deposited on Ag(111) at RT has been followed by measuring all spectral ranges of interest as a function of the amount of evaporated molecules. The results are shown in Fig. 1 for diverse coverages indicated in equivalent MLs (see Experimental section). At a coverage of  $\theta = 0.15$  ML of C<sub>60</sub>F<sub>48</sub> (light green spectra in Fig. 1) the C 1s core-level region presents a single peak at a BE = 284.2 eV, which is characteristic of C=C for C<sub>60</sub> on metals.<sup>33</sup> This result has been already demonstrated to arise from full de-fluorination of C<sub>60</sub>F<sub>48</sub> that transforms into C<sub>60</sub> when approaching some metal surfaces.<sup>14</sup> For such low coverage, fluorine atoms detached from the fullerene were not detected on either the Cu(111) or the Ni(111) surfaces. In contrast, for Ag(111) the emergence of a peak at the F





**Fig. 1** XPS spectra of the C 1s (a), F 1s (b) and Ag 3d (c) regions for clean substrate (black spectra) and the indicated amounts of  $C_{60}F_{48}$  (colored spectra) deposited at RT on Ag(111). Thin solid lines are the background and components of the data fits (see Experimental section and ESI†). The assignment of each component is indicated. The spectra were measured using  $h\nu = 515$  eV (for C 1s and Ag 3d) and 820 eV for F 1s. (d) Ratio between the intensity of the C–F and C–CF components as a function of deposited  $C_{60}F_{48}$ .

1s region is a proof of fluorine at the surface from the very early stages of  $C_{60}F_{48}$  de-halogenation. The corresponding low BE = 682 eV of the F 1s photoemission peak is typical of fluorine in metal fluorides (F-metal). Indeed, the unambiguous appearance of a second Ag 3d doublet on the low BE side of the  $Ag^0$  spectrum ( $\Delta BE = -0.6$  eV) indicate the presence of metal atoms in a  $Ag^+$  state, thus supporting the hypothesis of Ag–F bond formation. As commented in the introduction, in most elements, the core levels shift to higher BE with oxidation state, but in silver fluorides and silver oxides the trend is opposite (BE  $Ag^{++} < BE Ag^+ < BE Ag^0$ ). The exact mechanism that results in such a negative BE shifts is elusive. They have been explained in terms of differences

of the core hole screening in the diverse oxidation states,<sup>34</sup> ascribed to initial-state factors of ionic charge and lattice potential,<sup>23</sup> but also attributed to final state relaxation effects<sup>35</sup> and/or work function changes.<sup>36</sup> In the present case, the absolute value of the measured  $\Delta BE$  is close to that reported for  $AgF_2$ <sup>26,27</sup> and is ascribed to a relatively fluorine rich silver fluoride, arising from sequential de-fluorination of  $C_{60}F_{48}$  landing at the Ag(111) surface. At this early stage, we can already conclude that there is evidence of the formation of two fully differentiated on-surface products. First, the single C 1s peak (C=C) indicates that small amounts of  $C_{60}F_{48}$  deposited on Ag(111) completely lose their fluorine atoms and transform into  $C_{60}$ , as reported for Cu(111) and Ni(111).<sup>14</sup> Second, the single F 1s peak (F–Ag) and the splitted doublet of Ag 3d ( $Ag^0$  and  $Ag^+$ ) prove that a non-negligible amount of the detached fluorine atoms remain on the surface in the form of metal fluoride (Ag–F). We remark that fluoride formation was not detected for similar coverage on the other mentioned metals.<sup>14</sup> If it is assumed that all detached fluorine atoms remain on the surface, using simple geometric arguments in terms of the fullerene molecule *versus* fluorine atom sizes, one can estimate that complete de-fluorination of only  $\sim 0.085$  ML of molecules would yield a fluorine atom density corresponding to 1/3 of Ag lattice sites (see ESI†). At such an adatom density, halogens usually form a  $(\sqrt{3} \times \sqrt{3})R30^\circ$  superstructure on the fcc (111) surface of coinage metals. Even if we could not detect a clear diffraction pattern, we will show that the existence of a fluorine-rich ordered layer is in reasonable agreement with our results.

The presence of fluorinated fullerenes on Ag(111), indicative of a slowdown of de-fluorination, becomes evident for  $\theta = 0.3$  ML (light blue spectra in Fig. 1) with the emergence of the F 1s and C 1s core levels components corresponding to fluorine and carbon directly bonded (C–F and F–C) as well as that between carbon atoms in  $C_{60}F_x$  (C–CF). Above  $\theta = 0.3$  ML, the amount of fluorinated molecules overcomes the population of pure  $C_{60}$ , as seen by the evolution of C 1s and F 1s XPS in Fig. 1a–c, for  $\theta = 0.6$  ML, 0.9 ML and 2.2 ML. The intensity *versus*  $C_{60}F_{48}$  coverage plots for each XPS peak are provided in Fig. S1a–e of the ESI.†

Remarkably, the C–F and C–CF contributions to the C 1s, although displaying an overall increase with coverage (Fig. S1c and d, ESI†), are not linearly correlated up to reaching the monolayer, which indicates that molecular moieties with different fluorine content can coexist. Indeed, because the C 1s components of atoms in the fluorinated molecules are clearly discriminated from those of  $C_{60}$  (Fig. 1a) we can estimate the average fluorine content of the  $C_{60}F_x$  population as a function of molecular coverage. In a first approximation, the areal intensity ratio  $r = I(C-F)/I(C-CF)$  relates to the fluorination degree  $m/(60 - m)$  of a given fullerene ( $C_{60}F_m$ ). The ratio reported for  $C_{60}F_{48}$  in the gas phase<sup>32</sup> is close to the theoretical value ( $r = 4$ ) but it has been found to be much lower for  $C_{60}F_{48}$  on diamond surfaces.<sup>37</sup> The variability may have its origin on diverse facts influencing core level intensities during growth. Thus, in the present case, attenuation of each C–F would depend on the bond location (upper or lower part of the molecules) as well as on the specific 2D assembly geometry and growth mode (layer-by-layer *vs.* 3D growth). For example,



for a multilayer deposition (4 ML, brown spectra in Fig. 1c), where growth starts deviating from a layer-by-layer regime, the intensity ratio is  $r = 2.7$ , corresponding to an average value  $m = 44$ . Hence, the XPS intensity ratio  $r$  shown in Fig. 1d represents a spatially averaged value within the probing depth and should be used in qualitative terms. Following the full de-fluorination of molecules and  $C_{60}$  formation ( $r = 0$ ) for  $\theta \leq 0.15$  ML,  $r$  steeply increases and reaches a nearly constant value (corresponding to  $m = 40$ ) from  $\theta = 0.9$  ML. The observed evolution points to a progressive increase in the average fluorination, either in single molecules ( $C_{60}F_x$ ) and/or in the population of fully fluorinated species (of  $C_{60}F_{48}$ ).

The scenario derived from XPS, is further confirmed by UPS. Fig. 2 shows the VB spectra obtained by UPS ( $h\nu = 140$  eV) for the same  $C_{60}F_{48}/Ag(111)$  samples described above, including the Ag(111) substrate (black spectrum). Note that up to 0.9 ML, the Fermi edge step of the metallic substrate is detected, which is used as reference for BE in this regime. As expected, the F 2s XPS peaks display the same core level shift between F-Ag and F-C components, with BE = 27.5 eV and 32.5 eV, respectively (see extended range of BE in Fig. S2 of the ESI†) and follow the same behaviour of the F 1s spectrum, as formerly discussed.

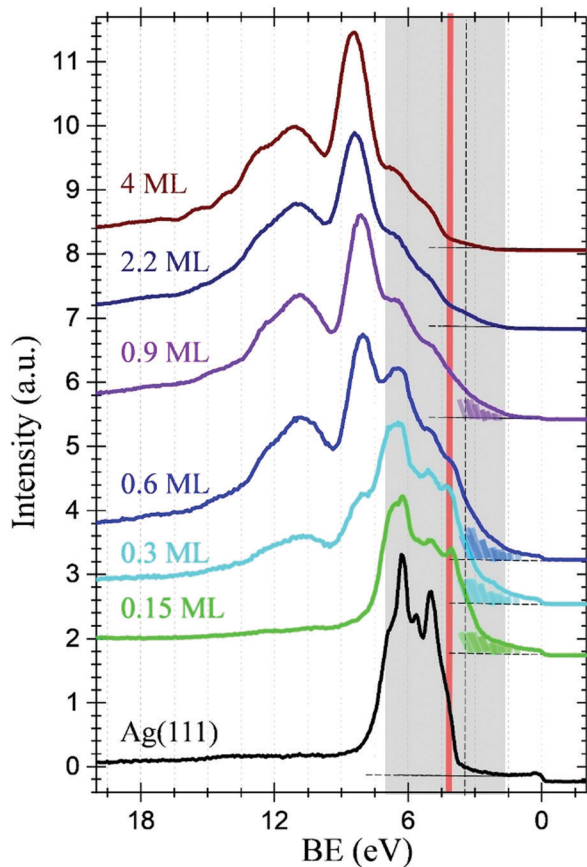


Fig. 2 UPS spectra of  $C_{60}F_{48}$  deposited at RT on Ag(111) for diverse coverages from  $\theta = 0.15$  ML to  $\theta = 4$  ML as indicated. The spectrum corresponding to the clean and bare Ag(111) is also shown (black spectrum). The DOS tails below 3 eV have been coloured to highlight the observed changes (see text). The spectra have been vertically shifted for clarity.

The presence of naked  $C_{60}$  at the silver surface would involve the existence of levels derived from the  $\pi$  orbitals at the low binding energy region.<sup>38</sup> In fact, even if the Ag 4d emission dominates this energy range at low coverage, three new sharp peaks are detected in the 7–4 eV range, which may be associated with the HOMO–3, HOMO–2 and HOMO–1 of naked  $C_{60}$ , respectively. An overall increase of the DOS, in the form of a tail below 3 eV (coloured areas under the corresponding spectra) is also observed. All the aforementioned spectroscopic features attenuate with increasing coverage, thus supporting the formation of  $C_{60}$  at the metal interface in the early stage of deposition. Other noticeable observation is the behavior of the fluorine F 2p associated to fluorinated molecules, whose binding energy (BE = 8.6 eV) has been reported to be independent of the fullerene fluorine content.<sup>39,40</sup> This state is accompanied by a characteristic broad (multicomponent) shake-up satellite (BE = 10.8 eV). These F 2p states are clearly absent in the early stage of deposition and they only appear at  $\theta = 0.3$  ML, further increasing with film thickness. Above the monolayer, the DOS attributed to  $C_{60}$  is no longer detected ( $\pi$ -derived molecular orbitals disappear) while two new shoulders emerge in the 4–7 eV energy range, whose intensity is related to the fluorine content of the fullerenes.<sup>32</sup> Reaching 2.2 ML, the spectrum reproduces all features seen at 4 ML that coincide quite precisely with those reported for the lower fluorine parent system  $C_{60}F_{36}$  on Au obtained at similar photon energy ( $h\nu = 120$  eV).<sup>39</sup> The depopulation of the HOMO states in the fluorinated fullerenes, with respect to the interfacial de-fluorinated  $C_{60}$ , is at the origin of the band gap increase that leads to the observed shift of the VB edge.

Fig. 3a shows the C K-edge NEXAFS spectra for the five consecutive deposition stages of  $C_{60}F_{48}/Ag(111)$  ranging from 0.15 to 2.2 ML. The dependence on surface orientation with respect to the (linear) polarization of the X-ray beam was monitored (see Experimental section), but only spectra measured in s-polarization are shown, as we did not detect significant differences in p-polarization below the ionization threshold for any film coverage. In Fig. 3b, we show the comparison of the spectra measured on a 4 ML film at RT with a reference spectrum measured on a 0.6 ML film of pure  $C_{60}$  deposited at RT. From the latter comparison, we identify that the NEXAFS spectrum at the lowest coverage of 0.15 ML displays several sharp features that are characteristic of pure  $C_{60}$ . The most relevant resonances associated with naked  $C_{60}$  are marked by black arrows in Fig. 3a and b, where the first two resonances correspond to the LUMO, LUMO+1/+2, as formerly reported.<sup>40–43</sup> The NEXAFS resonances of  $C_{60}F_{48}$  are much broader than  $C_{60}$  ones and some characteristic  $\pi^*$ -symmetry resonances of  $C_{60}$ , such as the LUMO+1/+2 doublet at 286 eV, simply vanish in the fluorinated compound due to the overall decrease of conjugation ( $sp^2$  bond states) originated by the F bonding ( $sp^3$  bond states). In detail, the fluorinated counterpart is characterized by a weak, but well resolved, resonance at  $\sim 282.5$  eV, as can be best appreciated at 2.2 and 4 ML. A pre-edge feature at energy lower than 284 eV was previously reported for other fullerene compounds with a lower content of fluorine.<sup>43</sup> The corresponding energy position decreases as the degree of



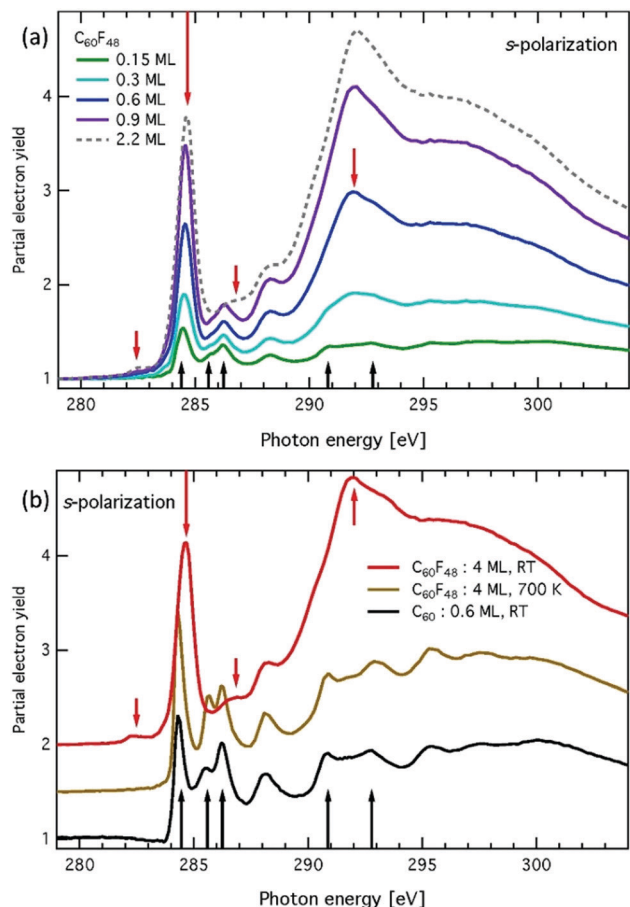


Fig. 3 C K-edge NEXAFS spectra for: (a) five consecutive  $C_{60}F_{48}$  depositions from  $\theta = 0.15$  ML to  $\theta = 2.2$  ML on Ag(111) at RT, (b) spectra for 4 ML of  $C_{60}F_{48}/Ag(111)$  at RT (black) and after annealing to 700 K. Black (red) arrows mark spectral features characteristics of  $C_{60}$  ( $C_{60}F_{48}$ ) molecules.

fluorination increases (the lowest one being recorded for the  $C_{60}F_{48}$  compound). In the present case, a generalized increase of the density of states in the 282.5–284 eV range is clearly observed at 0.6 ML, whose broad energy distribution is consistent with the coexistence of molecules with different degrees of fluorination. The most intense  $\pi^*$  resonance of  $C_{60}F_{48}$  is about twice as large as the corresponding  $C_{60}$  LUMO. It also displays a small shift to higher energy as a function of coverage, reaching the value of 284.5 eV already at 0.6 ML. Thanks to the absolute energy calibration of the present data (within 20 meV), we can ascertain that the energy of this resonance is larger than that of the  $C_{60}$  LUMO by 0.3 eV. A further shift to higher energy ( $\sim 0.1$  eV) of the main resonance is observed beyond 1 ML of deposited  $C_{60}F_{48}$ , which may be simply attributed to final state effects, *i.e.* vanishing of the core hole screening by the Ag Fermi electrons. The reliability of the above analysis is further explored by annealing the sample consisting of 4 ML  $C_{60}F_{48}/Ag(111)$  up to 700 K, temperature at which all fluorine atoms are expected to leave the molecules. All the fine details (including energy) of the  $\pi^*$  and  $\sigma^*$  band structures of  $C_{60}$  are fully developed after annealing, with only a minor discrepancy about the relative intensity between LUMO+1 and LUMO+2. In full

agreement with core levels and VB spectra, here again we see that the early stage of deposition yields the largest contribution to NEXAFS resonances from naked  $C_{60}$ , whereas the resonances of the fluorinated counterpart are clearly superimposed at  $\theta = 0.3$  ML.

In order to get further insight at the molecular level, we conducted some STM experiments. Fig. 4 shows a series of STM measurements for three different submonolayer coverages of the  $C_{60}F_{48}$  deposited at RT on the clean Ag(111). Atomic resolution images of the clean substrate were used for piezo calibration in the sub-nanometric range (see Fig. S3 in the ESI<sup>†</sup>), as well as reference images of domains of native  $C_{60}$  molecules at room temperature, which are known to form a  $(2\sqrt{3} \times 2\sqrt{3})R30^\circ$  commensurate phase with an intermolecular spacing of 10.0 Å (see Fig. S4 of ESI<sup>†</sup>). For a coverage as low as  $\theta = 0.1$  ML (Fig. 4a and b), small islands are formed both at steps and on terraces. At such a low coverage, most molecules arrange in a close-compact local ordering identical to that of pure  $C_{60}$  (Fig. S4, ESI<sup>†</sup>) including the intermolecular spacing and the

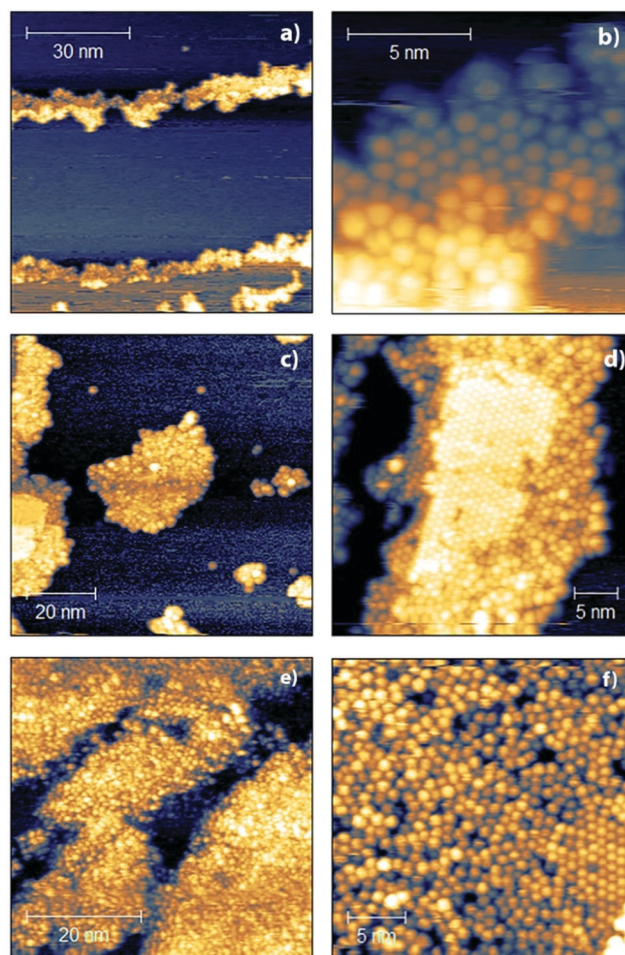


Fig. 4 STM topographic images of  $C_{60}F_{48}$  deposited at RT on Ag(111) for  $\theta = 0.1$  ML (a and b),  $\theta = 0.23$  ML (c and d) and  $\theta = 0.7$  ML (e and f). STM parameters: (a)  $V = 1.70$  V,  $I = 0.25$  nA; (b)  $V = -1.70$  V,  $I = -0.23$  nA; (c)  $V = 1.79$  V,  $I = 0.82$  nA; (d)  $V = 1.73$  V,  $I = 0.9$  nA; (e)  $V = 1.85$  V,  $I = 0.22$  nA; (f)  $V = 1.82$  V,  $I = 0.16$  nA.



hexagonal shape contrast of the molecules. At the rim of such ordered domains, one can appreciate a few irregular spaced molecules displaying diverse shapes and contrasts. We may assume these latter molecules to be fluorinated species (with diverse fluorine content), even if we cannot exclude they can be naked  $C_{60}$  on top of the formed AgF alloy, rather than on clean Ag(111). The result is an intermediate situation between similar STM experiments performed for  $C_{60}F_{48}$  on Cu(111) and Au(111), where full de-fluorinated and fluorinated molecules were respectively found<sup>14</sup> and quite similar to submonolayer deposits of  $C_{60}F_{18}$  on Au(111),<sup>15</sup> a fullerene with much lower fluorine content. At  $\theta \sim 0.2$  ML, we observe an increase on the spatial extent of the close-packed domains (Fig. 4d). At the same time, the relative population of non-ordered molecules has become almost equivalent to that of the ordered ones (Fig. 4c), strengthening the assignment of the irregular and disordered molecules to the fluorinated species (either totally or partially), in agreement with the spectroscopic indications, and further confirming that most de-fluorinated molecules are formed at the early stage of deposition. Finally, at a coverage of  $\theta \sim 0.7$  ML very large domains of quite disordered molecules cover most of the surface (Fig. 4e and f). At this point, the rare close-packed domains display irregular borders and contain many defects (vacancies, misoriented molecules, *etc.*). Even at such relatively large coverage, no second layer molecules are formed on top of the much extended molecular domains, *i.e.* molecules landing atop an island are quickly incorporated within the first layer. This implies a very large mobility of molecules on the surface, independently of their chemical state.

The irregular topographic appearance and the absence of ordered packing of fluorinated molecules may have several distinct explanations: it may originate (i) by the interaction between neighboring fullerenes with a different content of fluorine, (ii) or between equivalent molecules but facing with different orientation, (iii) or by the interaction with the AgF underneath.

However, at 0.2 and 0.7 ML, we could seldom detect a long range small-amplitude modulation along the  $\langle 110 \rangle$  symmetry direction with an average spacing of  $21.4 \pm 0.5$  Å corresponding to an incommensurate honeycomb pattern with periodicity of  $7.4 \pm 0.2$  r.l.u. (see Fig. 5). This weak modulation of the substrate contrast might originate by a small rippling of the AgF interface due to the accommodation of a small amount of fluorine in excess (see ESI†). The formation of long wavelength incommensurate patterns due to slight compression of the halogen overlayer has been reported for the case of chlorine on Ag(111), indeed.<sup>44</sup> Within this perspective, the fact that the periodicity of the honeycomb modulation is found to be the same at 0.2 and 0.7 ML is also consistent with the spectroscopic indication that most of fluorine atoms are released in the initial stage of deposition.

It is noteworthy remarking that although full de-fluorination takes place at room temperature for small depositions of  $C_{60}F_{48}$ , on Cu(111), detached fluorine atoms do not reside on the surface, which is in strong contrast with the unambiguous formation of silver fluorine on Ag(111). We suggest that the formed AgF layer contributes to inhibit both molecular surface

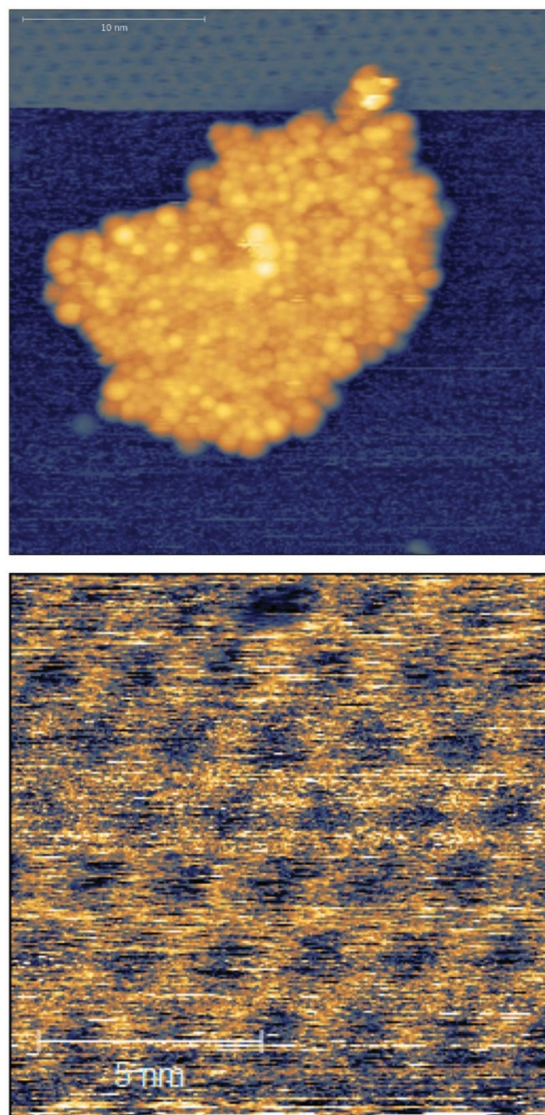


Fig. 5 Top: STM topographic images of  $\theta = 0.2$  ML of  $C_{60}F_{48}$  deposited on Ag(111) at: the tip change of contrast puts in evidence an irregular honeycomb pattern aside a large molecular domain (mostly disordered molecules). Bottom: the honeycomb motif with the same spacing is observed also for 0.7 ML of deposited  $C_{60}F_{48}$  on the uncovered substrate regions in between the molecular domains. STM parameters: (a)  $V = 1.79$  V,  $I = 0.69$  nA; (b)  $V = 0.86$  V,  $I = 1.65$  nA.

diffusion and the catalytic breaking of C–F bonds at the metal surface. The differences found on Ag(111) and Cu(111) cannot be right away rationalized from the expected interaction of fluorine with metals and give evidence of the complexity of the metal-catalysed on-surface reactions,<sup>21,22</sup> and their relevance in practical applications where molecule–metal interfaces play an active role.

## Conclusions

We provide a detailed description of the surface chemistry of  $C_{60}F_{48}$  deposited on Ag(111) at room temperature. The combination of *in situ* synchrotron-based spectroscopic techniques permits us to



identify the nature of the derived on-surface products. At the very first deposition stages ( $\leq 0.15$  ML), the molecules fully de-fluorinate and adsorb as  $C_{60}$ . The detached fluorine atoms remain on the surface and lead to the formation of a silver fluoride layer. At  $\sim 0.3$  ML, the appearance of the electronic states (deep core levels, valence band and empty density of states) of fluorine bound to carbon atoms puts in evidence the early decrease of de-fluorination on Ag(111). The fluorination degree of the adsorbed molecules increases progressively until the monolayer completion. In the real space, molecular resolution STM permits differentiating  $C_{60}$  from fluorinated fullerenes. While the former self-assemble in the known well-ordered close-packed 2D packing,  $C_{60}F_x$  aggregate highly disordered. The presence of a long-range 2D superstructure surrounding the molecular domains is interpreted in terms of the formed silver fluoride surface layer. The formation of silver fluoride on the surface inhibits the surface-induced catalytic breaking of C–F bonds.

With respect to the electronic properties, it follows that the formation of surface metal fluoride modifies the interface dipole, having herewith an impact on the surface work function and energy alignment at the molecule–metal interface.

## Conflicts of interest

There are no conflicts to declare.

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